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Electrochemical dissolution of fresh and passivated chalcopyrite electrodes. Effect of pyrite on the reduction of Fe³⁺ ions and transport processes within the passive film

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ABSTRACT

The effect of pyrite (FeS₂) on the electrochemical dissolution of fresh and passivated chalcopyrite (CuFeS₂) electrodes has been studied. Current density values for the dissolution of CuFeS₂ were calculated from EIS measurements. FeS₂ increased the dissolution rate of fresh and passivated CuFeS₂ electrodes indicating that the galvanic effect continued even after the electrode was chemically passivated. The dissolution rate of CuFeS₂ decreased by a factor of 3 after the passivation treatment. Due to the low diffusion rates of ions within the CuFeS₂ passive film and due to an increase in the resistance to the transfer of electrons at the electrode/film interface, the activity of FeS₂ for the reduction of Fe³⁺ ions was also reduced by a factor of 2.3 even though FeS₂ was not exposed to any chemical treatment. The results in this work indicate that the dissolution rate of the fresh CuFeS₂ electrode the dissolution rate was controlled by diffusion within the passive film.

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1. Introduction

Chalcopyrite (CuFeS₂) is the most abundant copper sulphide mineral accounting for nearly 70% of the known reserves in the world [1]. Hydrometallurgical processes continue to attract interest since they possess the ability to treat low tonnages of complex ores containing high impurities. However, due to the slow dissolution rates of CuFeS₂, hydrometallurgical processes have not yet found widespread application. In spite of this, there have been a number of processes developed for the leaching of CuFeS₂ and other copperbearing minerals; several of these processes have been reviewed by Baba et al. [2] and Dreisinger [3].

One of the latest developments in the chemical leaching of chalcopyrite in sulphate media under atmospheric pressure is the GalvanoxTM process. This process consists in the addition of pyrite (FeS₂) to the leach slurry in the presence of Fe³⁺ ions. FeS₂ and CuFeS₂ are thought to form a galvanic couple where FeS₂ acts as an extended surface for the reduction of Fe³⁺ ions, increasing in this way the rate of the anodic dissolution of CuFeS₂ [4,5]. Fig. 1 shows a simple schematic representation of the reactions that are thought to take place in the GalvanoxTM process. These reactions

http://dx.doi.org/10.1016/j.electacta.2014.01.165 0013-4686/© 2014 Elsevier Ltd. All rights reserved. are represented by Eqs. 1–4; Eq. 1 represents the anodic dissolution of CuFeS₂ to yield cupric and ferrous ions, as well as an elemental sulfur product layer that forms on the surface of the CuFeS₂ particle. The second reaction (Eq. 2) comprises the reduction of Fe³⁺ ions that are further regenerated by oxidizing Fe²⁺ ions with dissolved O₂ (Eq. 3). The overall reaction for the process is represented by Eq. 4.

$$CuFeS_2 \to Cu^{2+} + Fe^{2+} + 2S^0 + 4e^-$$
(1)

$$4Fe^{3+} + 4e^{-} \rightarrow 4Fe^{2+} \tag{2}$$

$$4Fe^{2+} + O_2 + 4H^+ \rightarrow 4Fe^{3+} + 2H_2O \tag{3}$$

$$CuFeS_2 + 4Fe^{3+} \rightarrow Cu^{2+} + 5Fe^{2+} + 2S^0$$
 (4)

The quality of FeS₂ as a catalyst depends on its source and its catalytic properties seem to be related to its silver content [6]. Nazari et al. [7] showed that the catalytic properties of different sources of FeS₂ could be enhanced by pretreating them with small amounts of silver. This effect was later suggested to be a consequence of a decrease in the electrical resistivity of the sulfur product layer covering the CuFeS₂ particles, thus facilitating the electrical contact between CuFeS₂ and FeS₂. A concomitant increase in the catalytic properties of FeS₂ for the reduction of Fe³⁺ ions was also postulated [8].







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Fig. 1. Schematic representation of the reactions taking place in the Galvanox $^{\rm TM}$ process.

The improvement of hydrometallurgical processes is strongly related to understanding the kinetics and mechanisms underlying the dissolution of minerals. It has been recognized that the main factors affecting the dissolution rate of $CuFeS_2$ are the concentration of the oxidizing species, the redox potential of the solution and the presence of a passivating layer [9–11].

Fe³⁺ ions are the most commonly applied oxidizing agent used in CuFeS₂ leaching [11 and references within]. It has been reported that the leaching rate of CuFeS₂ depends on Fe³⁺ ions when concentration is below 0.1 mol L⁻¹ whereas at higher concentrations no further increase in the dissolution rate is observed [12–14]. An explanation for this effect was given by Hirato et al. [15] who calculated that the concentration of Fe³⁺ and FeHSO₄²⁺ increased when total Fe concentration increased up to 0.1 mol L⁻¹ whereas for higher concentrations the predominant species was FeSO₄⁺. This explanation flows from the fact that, according to Ashurst and Hancock [16], the Fe³⁺ and FeHSO₄²⁺ species are outer-sphere complexes while FeSO₄⁺ is an inner-sphere complex where charge transfer is retarded since it involves the breaking of the Fe³⁺ and SO₄²⁻ bond to form the FeSO₄ outer-sphere complex. Thus only FeHSO₄²⁺ and Fe³⁺ would act as the electroactive species [17].

With regards to the rate determining step in the dissolution of CuFeS₂, Linge [18] demonstrated that pore diffusion through the sulphur film did not limit the dissolution rate; instead it was proposed that a solid diffusion process was the rate controlling step. Similarly, Dutrizac [19] studied the dissolution of CuFeS₂ in ferric sulphate and ferric chloride media and found that leaching rates were independent of acid concentration (for acid concentrations lower than $1 \mod L^{-1}$) and degree of agitation. More recently Ghahremaninezhad et al. [20] showed that any contribution of the Fe³⁺ reduction limiting current density could be neglected and that the major contribution to the dissolution current of a CuFeS₂ electrode came from charge transfer reactions; these authors also suggested that the passive film was a better electronic conductor than an ionic conductor and that the diffusion of atoms within the passive film was the reason for the slow reduction of Fe³⁺ on the surface of the electrode. There have also been several works reporting that the kinetics of CuFeS₂ leaching with Fe³⁺ occur under linear or parabolic kinetic chemical control regimes, with activation energies ranging from 40 to 130 kJ mol⁻¹ between 35 to 100 °C both in sulphate and chloride media [10,12,15,21-23].

As mentioned before, the presence of a passivating layer is one of the main factors affecting the leaching rate of chalcopyrite. This passivating layer causes the mineral to leach at very low rates, which is one of the main drawbacks of hydrometallurgical processes. In addition to this, the presence of a passivating layer complicates the analysis of the kinetics and mechanisms involved in the leaching of CuFeS₂. To date there are different theories regarding the nature of the passive layer formed during the leaching of the mineral and the nature and mechanisms of formation have been the subject of several articles and reviews [9,12,24–26]. The following passivating films have been suggested: elemental sulfur in both porous and compact layers; metal-deficient sulphides; polysulphides and, iron precipitates such as jarosite, $KFe_3(SO_4)_2(OH)_6$, and ferrihydrite, $Fe_5O_3(OH)_9$. Interestingly, regardless of the nature of this passive film, in a recent work Rivera [27] observed that adding FeS_2 to a $CuFeS_2$ concentrate that was showing signs of passivation increased the leaching rate and overcame the passivation effects observed prior to its addition. Similar results were observed when activated carbon was added to an enargite (Cu_3AsS_4) concentrate after having observed its passivation [28].

In the present work we have studied the effect of FeS_2 on the electrochemical dissolution of fresh and passivated $CuFeS_2$ electrodes. The dissolution current density values were determined using electrochemical impedance spectroscopy (EIS). The effect of the passive film on the dissolution rate of $CuFeS_2$ was also quantified. An experimental rate expression for the electrochemical dissolution of fresh $CuFeS_2$ electrodes was obtained and compared against a theoretical model based on mixed potential theory. A simple kinetic analysis was conducted to determine the rate controlling step on the dissolution of fresh and passivated $CuFeS_2$ electrodes.

2. Experimental

2.1. Mineral characterization

The CuFeS₂ sample used in this study was from the La Ranita mine in Chihuahua, Mexico. The mineral sample was analyzed by X-ray powder-diffraction (XRD) for quantitative phase analysis using the Rietveld method and the International Centre for Diffraction Database PDF-4 and Search-Match software by Bruker. The sample was reduced to the optimum grain-size range for quantitative X-ray analysis (<10 μ m) by grinding under ethanol in a vibratory McCrone Micronising Mill for 7 minutes. Step-scan XRD data were collected over a range 3-80° 2 θ with CoK α radiation on a Bruker D8 Focus Bragg-Brentano diffractometer equipped with an Fe monochromator foil, 0.6 mm (0.3°) divergence slit, incident- and diffracted-beam Soller slits and a LynxEye detector. The long fine-focus Co X-ray tube was operated at 35 kV and 40 mA, using a take-off angle of 6°.

2.2. Electrochemical techniques

The dissolution of a CuFeS₂ electrode was studied in a conventional three electrode cell. A CuFeS₂ electrode was used as working electrode, a graphite rod as counter electrode and a saturated calomel electrode (SCE, +0.24 V/SHE) as reference electrode. Most experiments were performed at 25 °C except for those performed during the passivation of the electrode at 50 °C. The working electrode consisted of cubic-shaped CuFeS₂ with an exposed surface of 1.9 cm². The CuFeS₂ electrode was fixed to a copper wire using silver-containing epoxy resin. The whole assembly was further embedded in a high temperature non-conductive epoxy resin. Prior to each electrochemical experiment the electrode was polished with 1200 grit carbide paper. Electrodes were rinsed with deionized water and acetone and left to dry. The polishing and acetone rinsing steps were omitted for the experiments with the passivated CuFeS₂ electrode to avoid changes in the formed product layer.

The electrolyte used in the experiments was a 0.5 mol L^{-1} H₂SO₄ (Fisher Scientific, 95 to 98%) aqueous solution prepared with deionized water; FeSO₄·7H₂O (Fisher Scientific, 100%) and Fe₂(SO₄)₃·5H₂O (Sigma Aldrich, 97%) were added in the desired concentrations. Nitrogen gas was sparged 30 minutes before and during the electrochemical experiments to remove dissolved oxygen from the electrolyte. The measured pH of the solutions used in this study was always in the range of 0.77–0.80.

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